

IN THE UNITED STATES PATENT AND TRADEMARK OFFICEIn re U.S. Patent Application of:
Fumihiko N. et al

Serial No.: 09/925,153

Filed: August 8, 2001

For: Insulating Nitride Layer and Process
for Its Forming, and Semiconductor
Device and Process for Its Production

Examiner: D. S. Blum

Group Art Unit: 2813

Confirmation No.: 3081

2813
RECEIVED
MAY - 1 2002
TECHNOLOGY CENTER 2800**RESPONSE TO RESTRICTION REQUIREMENT**Commissioner for Patents
Box Non-Fee Amendment
Washington, DC 20231

Dear Sir:

This amendment is being filed in response to the Office Action dated April 5, 2002. Please reconsider the application in view of the amendment and remarks presented below.

ELECTION OF CLAIMS

In the Office Action, the Examiner requested an election of claims pursuant to a restriction requirement under 35 U.S.C. §§ 121 between Group I claims 6-12 and 20-27 and Group II claims 1-5 and 13-19.

In response, the applicants hereby elect examination of Group II Claims 1-5 and 13-19 which are drawn to a layer and a device with that layer, classified in class 257, subclass 194.

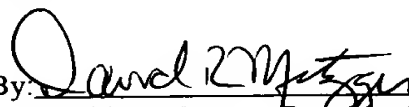
REMARKS

The Commissioner is hereby authorized to charge any fee, if necessary, to Account No. 19-3140 regarding this response. A duplicate copy of this transmittal letter is enclosed herewith.

Respectfully submitted,

SONNENSCHN NATH & ROSENTHAL

April 17, 2002

By: 
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I hereby certify that this document and any being referred to as attached or enclosed is being deposited with the United States Postal Service as first class mail in an envelope addressed to Assistant Commissioner for Patents, Washington, D.C. 20231, on

4.17.02
Date
Paula M. Theismann